

## VE320 Intro to Semiconductor Devices

### Summer 2024 – Problem Set 2

Due: 11:59pm, June 7<sup>th</sup>

1. (a) Determine the total number ( $\#/cm^3$ ) of energy states in silicon between  $E_C$  and  $E_C + 2kT$  at (i)  $T = 300K$  and (ii)  $T = 400K$ . (b) Repeat part (a) for GaAs.
2. (a) For silicon, find the ratio of the density of states in the conduction band at  $E = E_C + kT$  to the density of states in the valence band at  $E = E_V - kT$ . (b) Repeat part (a) for Ge.
3. Consider the energy levels shown in Figure 1. Let  $T = 300K$ . (a) If  $E_1 - E_F = 0.20eV$ , determine the probability that an energy state at  $E = E_1$  is occupied by an electron and the probability that an energy state at  $E = E_2$  is empty. (b) Repeat part (a) if  $E_F - E_2 = 0.40 eV$ .

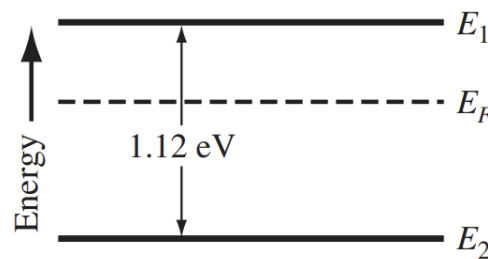


Figure 1. Energy levels for problem 3

4. (a) The carrier effective masses in a semiconductor are  $m_n^* = 1.21m_0$  and  $m_p^* = 0.70m_0$ . Determine the position of the intrinsic Fermi level with respect to the center of the bandgap at  $T = 300K$ . (b) Repeat part (a) if  $m_n^* = 0.80m_0$  and  $m_p^* = 0.75m_0$ .
5. Semiconductor A has a band gap of 1 eV, while semiconductor B has a band gap of 2 eV. What is the ratio of the intrinsic carrier concentrations in the two materials ( $n_{iA}/n_{iB}$ ) at 300 K. Assume any differences in the carrier effective masses may be neglected.
6. The value  $p_0$  in Silicon at  $T = 300K$  is  $2 \times 10^{16} cm^{-3}$ . (a) Determine  $E_F - E_V$ . (b) Calculate the value of  $E_C - E_F$ . (c) What is the value of  $n_0$ ? (d) Determine  $E_{Fi} - E_F$ .
7. The electron concentration in silicon at  $T = 300K$  is  $n_0 = 2 \times 10^5 cm^{-3}$ . (a) Determine the position of the Fermi level with respect to the valence band energy level. (b) Determine  $p_0$ . (c) Is it n- or p-type material?